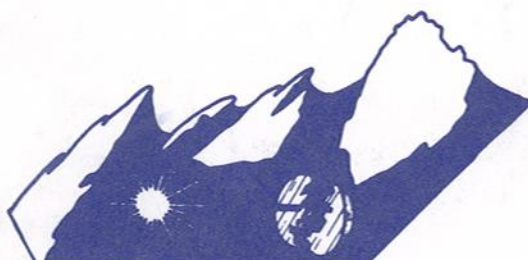


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Laser Induced Damage in Optical Materials: 1989



BOULDER DAMAGE SYMPOSIUM



SPIE Volume 1438



STP 1117

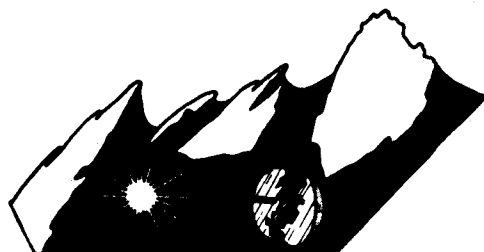
NIST SPECIAL PUBLICATION **801**

Laser Induced Damage in Optical Materials: 1989

Proceedings of the Boulder Damage Symposium, November 1-3, 1989

Sponsored by

National Institute of Standards and Technology
American Society for Testing and Materials
International Society for Optical Engineering
Defense Advanced Research Project Agency
Department of Energy



BOULDER DAMAGE SYMPOSIUM

October 1990

Edited by

Harold E. Bennett
Naval Weapons Center
China Lake, California 93555

Lloyd L. Chase
Lawrence Livermore National Laboratory
Livermore, California 94550

Arthur H. Guenther
Los Alamos National Laboratory
Los Alamos, New Mexico 87545

Brian E. Newnam
Los Alamos National Laboratory
Los Alamos, New Mexico 87545

M.J. Soileau
University of Central Florida
Orlando, Florida 32816



U.S. Department of Commerce
Robert A. Mosbacher, Secretary

National Institute of Standards and Technology
John W. Lyons, Director

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FOREWORD

The Proceedings contain the papers presented at the Twenty-First Symposium on Optical Materials for High-Power Lasers held at the National Institute of Standards and Technology in Boulder, Colorado, on November 1-3, 1989. The Symposium was sponsored jointly by the National Institute of Standards and Technology, the American Society for Testing Materials, the International Society for Optical Engineering, the Defense Advanced Research Project Agency, and the Department of Energy. The Symposium was attended by approximately 200 scientists from the United States, Canada, the United Kingdom, Japan, France, and the Federal Republic of Germany. It was divided into sessions devoted to the following topics: Materials and Measurements, Mirrors and Surfaces, Thin Films, and, finally, Fundamental Mechanisms. The Symposium Co-Chairmen were Harold E. Bennett of the Naval Weapons Center, Arthur H. Guenther of the Los Alamos National Laboratory, Lloyd L. Chase of the Lawrence Livermore National Laboratory, Brian E. Newnam of the Los Alamos National Laboratory, and M. J. Soileau of the University of Central Florida. They also served as editors of the proceedings.

The editors assume full responsibility for the summary, conclusions, and recommendations contained in the report, and for the summaries of discussion found at the end of each paper. The manuscripts of the papers presented at the Symposium have been prepared by the designated authors, and questions pertaining to their content should be addressed to those authors. The interested reader is referred to the bibliography at the end of the summary article for general references to the literature of laser damage studies. The Twenty-Second Annual Symposium on this topic will be held in Boulder, Colorado, October 24-26, 1990. A concerted effort will be made to ensure closer liaison between the practitioners of high-peak power and high-average power.

The principal topics to be considered as contributed papers in 1990 do not differ drastically from those enumerated above. We expect to hear more about improved scaling relations as a function of pulse duration, area, and wavelength, and to see a continuing transfer of information from research activities to industrial practice. New sources at shorter wavelengths continue to be developed, and a corresponding shift in emphasis to short wavelength and repetitively pulsed damage problems is anticipated. Fabrication and test procedures will continue to be developed, particularly in the diamond-turned optics and thin-film areas. It has been our intention to pause and reflect on progress over the past twenty years to the Symposium on Optical Materials for High Power Lasers. It will be our pleasure to present the last (Thin Film, the Second Decade) in a comprehensive array of tutorial lectures by distinguished workers in the field of laser induced damage in optical materials.

The purpose of these symposia is to exchange information about optical materials for high-power lasers. The editors will welcome comments and criticism from all interested readers relevant to this purpose.

H. E. Bennett, A. H. Guenther, L. L. Chase,
B. E. Newnam, and M. J. Soileau,
Co-Chairmen

DISCLAIMER

Certain papers contributed to this publication have been prepared by non-NIST authors. These papers have not been reviewed or edited by NIST; therefore, the National Institute of Standards and Technology accepts no responsibility for their accuracy, nor for their comments or recommendations.

Certain commercial equipment, instruments, and materials are identified in this publication in order to explain the experimental procedure adequately. Such identification in no way implies approval, recommendation, or endorsement by the National Institute of Standards and Technology, nor does it imply that the equipment, instruments, or materials identified are necessarily the best available for the purpose.

CONTENTS

	Page
FOREWORD	iii
H.E. Bennett, A.H. Guenther, L.L. Chase, B.E. Newnam, and M.J. Soileau	
DISCLAIMER.....	iv
SYMPOSIUM WELCOME	xii
M.J. Soileau	
SEARCH FOR TECHNOLOGY TRANSFER IN HIGH POWER OPTICS	xvi
C. Martin Stickley	
SUMMARY OF MEETING	1
H.E. Bennett, L.L. Chase, A.H. Guenther, B.E. Newnam, and M.J. Soileau	
1. Introduction	1
2. Overview.....	3
3. Acknowledgments.....	5
4. References.....	6

1989 INDEX - BOULDER DAMAGE SYMPOSIUM

MATERIALS AND MEASUREMENTS

Set of Standard Definitions for Laser Damage in Parameters and Procedures.....	9
J.W. Arenberg	
Optical Characterization of Transparent Materials Using Ellipsometry.....	10
S.F. Nee and H.E. Bennett	
Microindentation as a Technique For Assessing Subsurface Damage In Optics	25
R.S. Polvani and C. Evans	

Automated Damage Testing Facility for Excimer Laser Optics.....	39
K. Mann and H. Gerhardt	
Expanded Damage Test Facilities at LLNL.....	47
A.J. Morgan, F. Rainer, F.P. DeMarco, R.P. Gonzales, M.R. Kozlowski, and M.C. Staggs	
Laser Damage Database at 1064 nm.....	58
F. Rainer, R.P. Gonzales, and A.J. Morgan	
Damage Measurements on Optical Materials for Use in High-Peak-Power Lasers.....	74
F. Rainer, R.M. Brusasco, J.H. Campbell, F.P. DeMarco, R.P. Gonzales, M.R. Kozlowski, F.P. Milanovich, A.J. Morgan, M.S. Scrivener, M.C. Staggs, I.M. Thomas, S.P. Velsko, and C.R. Wolfe	
Laser Induced Damage to Thallium Arsenic Selenide(TAS).....	84
A.A. Said, M. Sheik-Bahae, M.J. Soileau, E.W. Van Stryland N.B. Singh, and T. Henningsen	
Laser Induced Damage in Schott's OG-550 Optical Absorption Glass.....	88
T. Whittaker, R. Goedert, and D. Templeton	
Effects of Laser Damage Processes on Microwave Propagation.....	96
R.S. Eng, M.D. Abouzahra, N.W. Harris, D.R. Cohn, and P.P. Woskov	
Laser Induced Damage to Silicon Photosensor Arrays.....	115
Chen-Zhi Zhang, Thierry Benchetrit, Steve E. Watkins, Rodger M. Walser, and Michael F. Becker	
Sensitive n_2 Measurements Using A Single Beam.....	126
M. Sheik-Bahae, A.A. Said, T.H. Wei, D.J. Hagen, E.W. Van Stryland, and M.J. Soileau	

Optical Breakdown in Particle Suspension.....	136
Kamjou Mansour, M.J. Soileau and E.W. Van Stryland	
Annealing of Induced Damage in Fluoride Glass Components.....	151
Osama H. El-Bayoumi, M.J. Suscavage, and L.P. De Rochemont	
The Effect of Laser Annealing on Laser Induced Damage Threshold.....	164
N.C. Kerr and D.C. Emmony	
Shockwave Detection, An Efficient Way to Determine Multiple-Pulse Damage Thresholds.....	180
S. Petzoldt, A.P. Elg, J. Reif, and E. Matthias	
Application of the Ronchi Ruling Beam Profiling Method to Axially Symmetric Laser Beams.....	187
Robert M. O'Connell and Cheng-Hao Chen	
Prediction of Laser Induced Damage by Comparison of Laser Fluence Profile to Damage Spot Radius.....	200
R. Goedert, T. Whittaker, and D. Templeton	
IR Laser Beam Profiling Using Quenched Fluorescence.....	214
N.C. Kerr, S.E. Clark and D.C. Emmony	
Laser-Induced Failure in Biased Silicon Avalanche Photodiodes.....	220
Steve E. Watkins, Chen-Zhi Zhang, Rodger M. Walser, and Michael F. Becker	

SURFACES AND MIRRORS

The Effect of Subsurface Defects on "Incipient" (Below Threshold) Laser Damage Nucleation In Fused Silica Optical Flats.....	230
T.J. Magee, C.S. Leung, F.D. Orazio, J.D. Boyer, B.R. Mauro, and V.E. Sanders	
Quantitative Analysis of Surface Trace Metal Contamination on Substrates and Films by TXRF.....	239
R. S. Hockett	

An Error Analysis of the Wyko TOPO Noncontact Surface Profiler.....	254
Van A. Hodgkin	
Ultra-Precision Grinding of LHG-8 Laser Glass and Laser Damage Thresholds.....	255
Y. Namba, K. Yoshida, H. Yoshida, and S. Nakai	
Low Scatter Surfaces on Silicon Carbide.....	256
Roger A. Paquin and Matthew B. Magida	
Physical Limits on Ultra-High Albedo Diffuse Reflectors.....	263
Perry Miles	
Optical Damage on SiO ₂ Cavity Mirrors Produced by High-Power VUV Laser Irradiation.....	267
Y. Takigawa, K. Kurosawa, M. Okuda, W. Sasaki, K. Yoshida, E. Fujiwara, Y. Kato, and Y. Inoue	
Damage Assessment and Possible Damage Mechanisms to 1-Meter Diameter Nova Turning Mirrors.....	278
G. Edwards, J. Campbell, R. Wolfe, E. Lindsey	
Thermal Transport Studies of Optical Coatings, Interfaces and Surfaces by Thermal Diffusion Wave Interferometry.....	291
Randall T. Swimm and Gary Wiemokly	
<u>Thin Films</u>	
Investigation of Thin Films Using Total Internal Reflection Microscopy.....	299
F.L. Williams, C.K. Carniglia, B.J. Pond, and W.K. Stowell	
Scattering Characterization of Materials in Thin Film Form.....	309
C. Amra	
Optical Properties and Laser Damage Measurements of Inorganic Polymer Films.....	324
Gregory J. Exarhos and Kevin M. Crosby	
Interfacial Stability in Optical Coatings.....	335
K.L. Lewis, A.M. Pitt, A.G. Cullis, K. Welford, and I.T. Muirhead	

Surface Analytical Methods for the Assessment of Damage in Optical Thin Films.....	350
James R. Hoenigman	
Laser Conditioning of Optical Thin Films.....	360
C.R. Wolfe, M.R. Kozlowski, J.H. Campbell, F. Rainer, A. J. Morgan, and R. P. Gonzales	
Large Area Laser Conditioning of Dielectric Thin Film Mirrors.....	376
M.R. Kozlowski, C.R. Wolfe, M.C. Staggs, and J.H. Campbell	
Population Distribution of Conditioned Damage Thresholds on AR Coated BK-7 Glass With Varing Laser Spot Size.....	393
D.W. Mordaunt and J.W. Arenberg	
Damage Threshold Measurements of Reflective and Transmissive Optics at 130 nm.....	403
C.H. Muller, III and C.E. Hamilton	
Laser Induced Damage Thresholds of Dielectric Coatings at 193 nm and Correlations to Optical Constants and Process Parameters.....	404
J. Kolbe, H. Müller, H. Schink, H. Welling, and J. Ebert	
Angular Dependence of Thin-Film Dielectric Coating Damage Thresholds Revisited.....	417
J. D. Boyer, S. R. Foltyn, B. R. Mauro, and V. E. Sanders	
Pulse-width Dependence of Optical Coating Damage at 1052 nm.....	425
K. Yoshida, S. Ikunishi, H. Yoshida, Y. Kato, and S. Nakai	
Damage Resistant Optical Coatings Prepared Using High Temperature, Plasma Chemical-Vapor Deposition.....	426
J.H. Campbell, J.L. Emmett, R.M. Brusasco, F. Rainer, R.Th. Kersten, V. Paquet, and H.W. Etzkorn	
A High Temperature, Plasma-Assisted Chemical Vapor Deposition System.....	443
R.M. Brusasco, J.A. Britten, C.B. Thorsness, M.S. Scrivener, W.G. Unites, J.H. Campbell, and W.L. Johnson	

The Evolution of Molecular Beam Deposition (MBD) from Laboratory to Production Usage.....	455
C.C.H. Hale, I.T. Muirhead, S.P. Fisher, G.J.H. Mathew	
Investigation and Modelling of Laser Damage Properties of Fabry-Perot Filters.....	471
A. McInnes, C.M. MacDonald, D.R. Gibson and A.D. Wilson	
High Damage Threshold AlO.OH-SiO ₂ HR Coatings Prepared by the Sol-Gel Process.....	484
Ian M. Thomas	
1-on-1 and n-on-1 Laser Strength of Binder Aided ZrO ₂ and ZrO ₂ -SiO ₂ Reflective Sol-Gel Coatings.....	490
H.G. Floch and J.J. Priotton	
Structural Modification of D ₂ O/H ₂ O-Dosed CaF ₂ Optical Thin Films.....	509
J.B. Franck	

FUNDAMENTAL MECHANISMS

Non-Avalanche Dielectric Breakdown in Wide-Band-Gap Insulators at DC and Optical Frequencies.....	528
P. Braunlich, S.C. Jones, X.A. Shen, R.T. Casper, E. Cartier, D.J. DiMaria, M.V. Fischetti, and P. Kelly	
UV Seeding of IR Laser Induced Damage.....	541
N.C. Kerr, S.E. Clark and D.C. Emmony	
Measurements of uv Induced Absorption in Dielectric Coatings.....	551
M.H. Bakshi, M. Cecere, D.A.G. Deacon, and A.M. Fauchet	
The Response of Multilayer Dielectric Coatings to Low Fluence Ultraviolet Light Exposure.....	561
V.E. Sanders, J.W. Early, and W. Leamon	
Radiation Damage in Single Crystal CsI (Tl) and Polycrystal CsI.....	568
O. Barnouin, A. Procoli, H. Chung, and G.H. Miley	

Effects of Thermal Conductivity and Index of Refraction Variation on the Inclusion Dominated Model of Laser-Induced Damage.....	576
M.Z. Fuka, J.K. McIver, and A.H. Guenther	
Theoretical Determination of the Nonlinear Optical Properties of Inorganic Polymers.....	584
Steven M. Risser and Kim F. Ferris	
Relation Between n_2 and Two-Photon Absorption.....	591
M. Sheik-Bahae, D.J. Hagan, E.W. Van Stryland, T.H. Wei A.A. Said, E. Canto, and A. Miller	
Photoconductivity of ZnS and ZnSe.....	598
B.E. Mason and C.D. Marrs	
Formation of a Pregiven Reflecting Surface Topography by Elastic Deformation of the Mirror Substrate. New Concept of Adaptive Optical System.....	606
V.V. Apollonov, S.A. Chetkin, E.A. Ivanova, A.M. Prokhorov, G.V. Vdovin	
Application of Ultrasonic Capillary Effect in Elements of Power Optics Cooled by Means of a Heat Pipe.....	618
V.V. Apollonov, S.A. Chetkin, V.N. Kharchenko, V.N. Motorin, and A.M. Prokhorov	
Appendix I. List of Attendees.....	631

WELCOME FOR 21st BOULDER DAMAGE SYMPOSIUM

M. J. Soileau
Professor of Electrical Engineering and Physics
Director, Center for Research in Electro-Optics and Lasers
University of Central Florida
Orlando, Florida

It is my pleasure and duty to call this year's meeting to order. I was abroad when the final program was put together by my co-chairs and did not learn of this honor until a couple of weeks ago. I had no time to prepare until this weekend, so this will be a bit rough and without the benefit of elegantly prepared slides.

I don't mean to take a stab at my co-chairs, but I must admit that as I began my preparation I couldn't remember a single thing about previous opening remarks by my esteemed colleagues! Did I miss something? Surely these distinguished leaders of national laboratories must have said something profound and prophetic! So I spent part of the day Saturday reviewing the past utterances which have launched this meeting.

It is true that the memory is the second thing to go, because as I read the opening remarks for the past 20 meetings, I found many, profound statements--a few of which are listed below:

This is a quote from the next speaker from 1972:

"It is a pleasure to be here this afternoon."
Martin Stickley, 1972.

"Whatever turns you off." (Alex's definition of damage)
Alex Glass, 1974

"A name which invokes images of people cracking rocks."
Alex Glass, 1976. (In response to Martin Stickley's call for a more positive sounding name for the conference.)

"Our onion unfortunately, exists in Hilbert Space." (Alex borrowing from an ancient philosopher's description that learning is like peeling an onion--each layer exposes another.)

"Who cares?" (Alex on why study damage?)
Alex Glass, 1976.

"It is my annual hope that each year's symposium will be the last." (Alex the failed prophet.)
Alex Glass, 1978.

"The key...is terawatts per megabuck.
Alex Glass, 1978.

"Power Optics." (A supplier of megabucks at the time in comparing laser optics to electronics.)
Harry Winsor, 1978.

"Aside from a gain medium, lasers require mirrors." (Insightful words from the great visionary.)
Harry Winsor, 1978.

"Progress has been made, but I am confident that in 10 years we will celebrate the 20th and Art and Alex will still be running it!" "...we owe a debt to these 2 young men." (Note the term young.)
Martin Stickley, 1978.

To this point I've spared you the profound utterance of my current co-chairs such as:

"Welcome to the Tenth Anniversary Damage Symposium." (Art Guenther gave this greeting at the 11th meeting.)
Art Guenther, 1979.

Then there were profound things said regarding the international participation.

"...countries represented include the British Isles, Canada, England, France, Japan, Scotland, and West Germany:"
Brian Newnam, 1980.

"International contributors...have come a long way..."
Hal Bennett, 1985.

It should be clear to all how difficult it is for me since these guys have used up all the good stuff! Further review of these openings presented me with a good outline for my remarks. I will follow the trail blazed by my predecessors:

Outline

1. Welcome participants.
2. Acknowledge sponsorship of NIST, ASTM, and others.
3. Count the papers for this year's meeting and comment on the statistical distribution.
4. Observe that thin films are a major problem.
5. Profound and prophetic statement about the future of the meeting.

I do welcome you to the 20th Anniversary Boulder Damage Symposium. Those of you who are still asleep or partially hung over, may be confused by the fact that last year was our 20th Anniversary celebration. The resolution of this dilemma is the fact that last year was the 20th meeting and this is

the 20th Anniversary (but the 21st meeting). One might say that this meeting is old enough to drink - but you will also note that there is no wine and cheese this year. This situation has resulted from rulings by NIST accountants. In fact, the accountants have made it difficult for us to conduct business as usual, so you can expect further changes next year.

We do want to thank NIST and the ASTM for their continued sponsorship and all the helpful folks at Boulder who make the meeting run smoothly.

There are about 70 papers this year with contributions from 6 countries in addition to the U.S. The talks from abroad constitute 27% of the papers, about the same percentage as from Livermore and Los Alamos. About an equal number of papers come from U.S. aerospace companies (15%) and U.S. universities (16%). About 9% are from DoD labs and the remaining 8% from various other sources.

Our next speaker (Martin Stickley) has suggested on a number of occasions that the name of the conference be changed to something more positive. I want to finish this presentation by noting that there are many positive things being done with phenomena studied by participants in these meetings. Here is a list of a few:

"Spin Offs" of LID Phenomena

1. Laser marking, cutting and drilling of materials.
2. Laser medicine
 - a. laser scalpel
 - b. laser-induced breakdown for eye treatments and plaque removal.
3. Laser disc storage - the first application of LID to consumer products.
4. Photorefractive information storage, processing, and phase conjugation interconnects.
5. Nonlinear refraction and nonlinear absorption for limiters, switches, and optoelectronic computing.
6. Electro-absorptive switches using UHV manufactured quantum well devices (SEED's).

So I issue a challenge to us all to keep the name Damage Symposium, but continue to seek positive applications of the phenomena we study. A wise professor once told me that phenomena are neither good or bad--they exist and it's up to us to find ways to make good things using phenomena given by nature.

Before I left Orlando, I looked into by crystal ball for a glimpse of future laser damage or optical materials problems--here is my short list:

Future Topics for Optical Materials Research

1. Thin films for all applications. Two talks viewing 20 years of thin film work.

2. New laser host and nonlinear optical materials for compact, efficient, tunable and solid state lasers for many old and many new applications.
3. X-ray optics for lasers (remember Harry Winsor said that lasers have mirrors...), and optics for x-ray microscopy and x-ray lithography.
4. Materials for x-ray lithography.

I'm sure that these and other topics will keep optical materials people busy for some time--the only question is where will the funding come from? DoD funding will surely decline as peace is breaking out all over. DOE funding usually finds its way to the national labs--but not much finds its way out. DARPA, under Martin Stickley's leadership, provided much of the spark that lead to modern day materials and much of the research reported at this conference. Materials research tends to be too long-term for present day funding. We need to all do our part in ensuring continued research support for the foundation of the technology food chain--materials research.

Since we don't have an official wine and cheese gathering, I hereby propose that we forgo small gatherings of old friends for dinner, etc. and meet instead at the Dark Horse for an informal, pay as you go, social hour.

SEARCH FOR TECHNOLOGY TRANSFER IN HIGH POWER OPTICS

C. Martin Stickley

BDM International, Inc.
1300 N. 17th St., Suite 950
Arlington, VA 22209

In the late 60's and through the 70's, DARPA supported a broad program to develop optics for use with high power cw CO₂ lasers and new laser and nonlinear optical materials. This paper summarizes those efforts and asks anyone who knows in what defense systems these have been used to contact the author.

In the late 1960's and through the 1970's, the Materials Sciences Office (now the Defense Sciences Office) of the Defense Advanced Research Projects Agency (DARPA) funded a broad program to develop optics for high power continuous development of approaches to fabricate large area windows with high transparency (absorption of 10⁻⁵ per cm), optical surface preparation techniques which leave very little residual absorption, and techniques for depositing antireflection as well as reflecting coatings for transparent windows and mirrors. Some development of new laser and nonlinear optical materials was also funded. Approximately \$22.9 M dollars were spent between 1967 and 1978.

The Defense Sciences Office is now searching for examples of where optical parts fabricated using these techniques and the laser and NLO materials have been used in defense systems. While defense uses are of primary importance, NASA and industrial uses are also of interest.

Technologies which may have had the best chance of being utilized include, for windows: casting of fluorides, reactive atmosphere processing of halides, forging of halides, and CdTe growth, distortion and damage studies; for surfaces and coatings: polymers and surface preparation of halides, fluorides, and selenides; for lasers: erbium glass, and holmium and erbium in YLF; for mirrors: beryllium optics; and for laser damage: platinum removal and surface preparation of Owens-Illinois glass, and bulk and surface damage of ruby.

The tables which follow summarize the activities which were supported in each major area. Included are the specific technology developed (e.g. fluoride fusion casting), the contractor, the amount of funding provided, and at the time period where the work was done.

If the reader knows of areas where any of these technologies may have been used in defense systems (as well as for NASA and the commercial sector), please contact the author.

LASER WINDOW MATERIALS

Fluorides

● Fluoride Fusion Casting	Raytheon	166K	76-77
● Scaling of Fluoride Casting	Raytheon	790K	74-76

Halides

● Halide Superalloys for High Power Windows	Raytheon	191K	72-73
● Halide OH Removal	Hughes Res. Labs	174K	72
● Reactive Atmosphere Processing	Hughes Res. Labs	215K	76-78
● RAP of KBR	Hughes Res. Labs	244K	74-76
● Extrusion and Cross-Rolling	Honeywell	1 95K	72-73
● Forging of Alkali Halides	Honeywell	1483K	73-78
● Radiation Hardening	Oklahoma	113K	72-74
● Press Forging Halides	NRL	521K	72-75
● RAP of KBR - Characterization	NRL	80K	76

LASER WINDOW MATERIALS

II-VI Materials

● II-VI Distortion and Damage	USC	1336K	72-77
● CVD of Cadmium Telluride	Raytheon	192K	73-75
● CVD of CdTe and GaP	Raytheon	196K	75-77
● Characterization of II-VI Materials	MIT	308K	73-76

Chalcogenides

● Oxygen-Free Chalcogenides	Catholic University	283K	72-74
● Structure-Dependent Absorption	Texas Instruments	72K	73-74

Other

● Covalent Carbon Window Materials	UCLA	114K	75-76
● Copper-Leaded CERVIT	Owens Illinois	27K	76

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LASER WINDOW MATERIALS

Measurement Techniques

● Spectroscopy of Halides	Cornell	209K	75-76
● Emissivity Facility	Block Eng.	250K	73-75
● Multiple Wavelength Calorimetry	Alabama	58K	74-76
● Chemical Laser Window Absorption	Raytheon	60K	74-75
● CO ₂ Laser Window Evaluation	AVCO	279K	75-76
● Proof Testing	MIT	168K	75-76
● Mechanical Properties	MIT	320K	72-75

Theory

● Theory of Coatings and UV Materials	Xonics	1342K	72-78
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LASER COATINGS AND SURFACES

● Polymer Protective Coatings	UC Berkeley	169K	75-77
● Polymer Protective Coatings	Rockwell	149K	73-74
● Surface and Coating Technology	Hughes Res. Lab	1076K	73-76
● Window Polishing and Characterization	NWC	1696K	72-77
● Passive Characterization/HF Coatings	NWC	1042K	76-77
● Coating Stress Measurements	Perkin Elmer	200K	76-77
● Coating Growth and Stress	AFCRL	255K	73-75
● Transparent Abrasives	Raytheon	207K	73-75

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LASER MATERIALS

●	Erbium Glass	American Optical	191K	69-71
●	Holmium in YLF	Sanders Associates	203K	71-73
●	Near Visible Laser Materials	Sanders Associates	270K	72-75
●	Ceramics for Lasers	Union Carbide	193K	1977
●	Wide Linewidth Materials	Texas Instruments	225K	72-73

MIRRORS AND SURFACES

●	Beryllium for Optics	Perkin Elmer	1434K	Prior to 69
●	Ion Beam Optical Figuring	Kollsman	146K	Prior to 69

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NONLINEAR OPTICAL MATERIALS

●	Cinnabar	Tyco	190K	70-71
●	Chalcopyrite	Stanford	279K	70-74
●	High Damage Threshold Materials	Isomet	98K	1973
●	Chalcogenides	Westinghouse	230K	72-75
●	IR Laser Components	Westinghouse	201K	Before 1969
●	IR Quantum Counter	Purdue		

DAMAGE TO LASER MATERIALS

Glass

- | | | | |
|---------------------------|----------------|------|-------|
| ● Laser Glass Damage | Owens Illinois | 616K | 69-71 |
| ● Glass Surface Treatment | Owens Illinois | 291K | 72-73 |

Ruby

- | | | | |
|---------------------------|------------------|------|-------|
| ● Bulk and Surface Damage | Hughes Res. Labs | 400K | 69-71 |
|---------------------------|------------------|------|-------|

Measurement Techniques

- | | | | |
|-----------------------------|-----|-------|-------------|
| ● Laser Measurements | NBS | 2369K | Prior to 69 |
| ● Laser Damage Measurements | NBS | 161K | 72-73 |

Mirrors

- | | | | |
|------------------------------|-------------|------|-------|
| ● RF Sputtered Metal Mirrors | Battelle NW | 450K | 72-73 |
|------------------------------|-------------|------|-------|

Research

- | | | | |
|------------------------|--|------|-------|
| ● Miscellaneous Topics | Harvard, NWC,
USC, AFCRL,
Raytheon, Bendix | 749K | 71-76 |
|------------------------|--|------|-------|

LASER WINDOW MATERIALS

Fluorides

● Fluoride Fusion Casting	Raytheon	166K	76-77
● Scaling of Fluoride Casting	Raytheon	790K	74-76

Halides

● Halide Superalloys for High Power Windows	Raytheon	191K	72-73
● Halide OH Removal	Hughes Res. Labs	174K	72
● Reactive Atmosphere Processing	Hughes Res. Labs	215K	76-78
● RAP of KBR	Hughes Res. Labs	244K	74-76
● Extrusion and Cross-Rolling	Honeywell	1 95K	72-73
● Forging of Alkali Halides	Honeywell	1483K	73-78
● Radiation Hardening	Oklahoma	113K	72-74
● Press Forging Halides	NRL	521K	72-75
● RAP of KBR - Characterization	NRL	80K	76

LASER WINDOW MATERIALS

II-VI Materials

● II-VI Distortion and Damage	USC	1336K	72-77
● CVD of Cadmium Telluride	Raytheon	192K	73-75
● CVD of CdTe and GaP	Raytheon	196K	75-77
● Characterization of II-VI Materials	MIT	308K	73-76

Chalcogenides

● Oxygen-Free Chalcogenides	Catholic University	283K	72-74
● Structure-Dependent Absorption	Texas Instruments	72K	73-74

Other

● Covalent Carbon Window Materials	UCLA	114K	75-76
● Copper-Leaded CERVIT	Owens Illinois	27K	76

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LASER WINDOW MATERIALS

Measurement Techniques

● Spectroscopy of Halides	Cornell	209K	75-76
● Emissivity Facility	Block Eng.	250K	73-75
● Multiple Wavelength Calorimetry	Alabama	58K	74-76
● Chemical Laser Window Absorption	Raytheon	60K	74-75
● CO ₂ Laser Window Evaluation	AVCO	279K	75-76
● Proof Testing	MIT	168K	75-76
● Mechanical Properties	MIT	320K	72-75

Theory

● Theory of Coatings and UV Materials	Xonics	1342K	72-78
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LASER COATINGS AND SURFACES

● Polymer Protective Coatings	UC Berkeley	169K	75-77
● Polymer Protective Coatings	Rockwell	149K	73-74
● Surface and Coating Technology	Hughes Res. Lab	1076K	73-76
● Window Polishing and Characterization	NWC	1696K	72-77
● Passive Characterization/HF Coatings	NWC	1042K	76-77
● Coating Stress Measurements	Perkin Elmer	200K	76-77
● Coating Growth and Stress	AFCRL	255K	73-75
● Transparent Abrasives	Raytheon	207K	73-75

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LASER MATERIALS

● Erbium Glass	American Optical	191K	69-71
● Holmium in YLF	Sanders Associates	203K	71-73
● Near Visible Laser Materials	Sanders Associates	270K	72-75
● Ceramics for Lasers	Union Carbide	193K	1977
● Wide Linewidth Materials	Texas Instruments	225K	72-73

MIRRORS AND SURFACES

● Beryllium for Optics	Perkin Elmer	1434K	Prior to 69
● Ion Beam Optical Figuring	Kollsman	146K	Prior to 69

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NONLINEAR OPTICAL MATERIALS

● Cinnabar	Tyco	190K	70-71
● Chalcopyrite	Stanford	279K	70-74
● High Damage Threshold Materials	Isomet	98K	1973
● Chalcogenides	Westinghouse	230K	72-75
● IR Laser Components	Westinghouse	201K	Before 1969
● IR Quantum Counter	Purdue		

DAMAGE TO LASER MATERIALS

Glass

- | | | | |
|---------------------------|----------------|------|-------|
| ● Laser Glass Damage | Owens Illinois | 616K | 69-71 |
| ● Glass Surface Treatment | Owens Illinois | 291K | 72-73 |

Ruby

- | | | | |
|---------------------------|------------------|------|-------|
| ● Bulk and Surface Damage | Hughes Res. Labs | 400K | 69-71 |
|---------------------------|------------------|------|-------|

Measurement Techniques

- | | | | |
|-----------------------------|-----|-------|-------------|
| ● Laser Measurements | NBS | 2369K | Prior to 69 |
| ● Laser Damage Measurements | NBS | 161K | 72-73 |

Mirrors

- | | | | |
|------------------------------|-------------|------|-------|
| ● RF Sputtered Metal Mirrors | Battelle NW | 450K | 72-73 |
|------------------------------|-------------|------|-------|

Research

- | | | | |
|------------------------|--|------|-------|
| ● Miscellaneous Topics | Harvard, NWC,
USC, AFCRL,
Raytheon, Bendix | 749K | 71-76 |
|------------------------|--|------|-------|

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11. ABSTRACT (A 200-WORD OR LESS FACTUAL SUMMARY OF MOST SIGNIFICANT INFORMATION. IF DOCUMENT INCLUDES A SIGNIFICANT BIBLIOGRAPHY OR LITERATURE SURVEY, MENTION IT HERE.) The Twenty-First Annual Symposium on Optical Materials for High-Power Lasers (Boulder Damage Symposium) was held at the National Institute of Standards and Technology in Boulder, Colorado, November 1-3, 1989. The Symposium was sponsored jointly by the National Institute of Standards and Technology, the American Society for Optical Engineering, the Defense Advanced Research Project Agency, and the Department of Energy. Approximately 200 scientists including representatives of the United Kingdom, France, Japan, Canada, and the Federal Republic of Germany, attended the Symposium. The Symposium was divided into sessions concerning Materials and Measurements, Mirrors and Surfaces, Thin Films, and, finally, Fundamental Mechanisms. As in previous years, the emphasis of the papers presented at the Symposium was directed toward new frontiers and new developments. Particular emphasis was given to materials for high power apparatus. The wavelength range of the prime interest was from 10.6 μm to the uv region. Highlights included surface characterization, thin film substrate boundaries, and advances in fundamental laser-matter threshold interactions and mechanisms. The scaling of damage thresholds with pulse duration, focal area, and wavelength was discussed in detail. Harold E. Bennett of the Naval Weapons Center, Arthur H. Guenther of the Los Alamos National laboratory, Lloyd L. Chase of the Lawrence Livermore National Laboratory, Brian E. Newnam of the Los Alamos National Laboratory, and M. J. Soileau of the University of Central Florida were co-chairmen of the Symposium. The Twenty-Second Annual Symposium is scheduled for October 24-26, 1990, at the National Institute of Standards and Technology, Boulder, Colorado.				
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